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**Abstract**

The present invention provides a chemical amplification type positive resist composition comprising resin which itself is insoluble or poorly soluble  
5 in an alkali aqueous solution but becomes soluble in an alkali aqueous solution by the action of an acid, an acid generator and a compound having an aromatic ring, having a molecular weight of 1000 or less and showing light absorption of a 1000 liter/(mol\*cm) or more in terms of molar extinction coefficient in a wavelength range from 190 nm to 260 nm, wherein the ratio  
10 of said compound is 0.01 to 20 % by weight based on the resin.